IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

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In re Patent Application of:						
Joo-Ho KIM et al.						
Application No.: Unassigned		Group Art Unit: Unassigned				
Filed: March 24, 2	005	Examiner: Unassigned				
For: HIGH DENSITY RECORDING MEDIUM WITH SUPER-RESOLUTION NEAR-FIELD STRUCTURE MANUFACTURED USING HIGH-MELTING POINT METAL OXIDE OR SILICON OXIDE MASK LAYER						
	. INFORMATION DISCLO	SURE STATEMENT				
Commissioner for PO Box 1450 Alexandria, VA 223						
Sir: In accordance with the duty of disclosure provisions of 37 CFR § 1.56, there is hereby provided certain information which the Examiner may consider material to the examination of the subject U.S. patent application. It is requested that the Examiner make this information of record if it is deemed material to the examination of the subject application.						
1. End	closures accompanying this Info	rmation Disclosure Statement are:				
1a. ⊠ 1b. ⊠	Form PTO-1449. Copy(ies) of IDS citation(s), examplication publications.	xcept for U.S. Patents and U.S. Patent				
1c. 🛚		ommunication(s) from a foreign Patent Office				
1d. 🛚	English language translation (complete, Abstract or relevant portion(s)) lage publications as indicated on the attached				
1e. 🗌	Explanations of Relevancy of	References (ATTACHMENT 1(e), hereto) for on of each non-English publication.				
 In accordance with 37 CFR § 1.98, a concise explanation of what is presently understood to be the relevance of each non-English language publication is (Check appropriate Items 2a, 2b, 2c and/or 2d) 						
2a. 🛚	"English language version of t degree of relevance found by	anguage publication(s) cited on the enclosed the search report or action which indicates the the foreign office". (See MPEP § 609, Information Disclosure Statement, Part A(3):				
2b. 🗌	set forth in the application.	ance, our Ed., Nev. 2)				

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an English language translation (Abstract only) attached to each non-English language publication as indicated on the attached Form PTO-1449.

2d. enclosed as Attachment 1(e), hereto.

No admission is made that the information cited in this Statement is, or is considered
to be, material to patentability nor a representation that a search has been made
(other than search report(s) from a counterpart foreign application or a PCT
International Search Report. if submitted herewith). 37 CFR §§ 1.97(o) and (h).

Respectfully submitted,

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Dated: 3/24

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FORM PTO-1449

U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE ATTORNEY DOCKET NO.

0001.1045

FIRST NAMED INVENTOR

JOO-HO KIM et al.

FILING DATE

GROUP ART UNIT

Unassigned

LIST OF REFERENCES CITED BY APPLICANT

(Use several sheets if necessary)

119	DATE	NT D	CHR	ENT

			U.S. PAI	IENT DOCUMENTS			
*EXAMINER INITIAL		DOCUMENT NO.	DATE .	NAME	CLASS	SUB- CLASS	FILING DATE
/KB/	AA	2002/0154596 A1	10/2002	HSU et al.			
	AB					/	
	AC						
	AD						
	AE						

FOREIGN PATENT DOCUMENTS

		DOCUMENT NO.	DATE	COUNTRY	TRANSLATION/ YES NO	ABSTRACT
/KB/	AF	KR 2000-14590	03/2000	Republic of Korea		Х
/KB/	AG	JP 2000-285536	10/2000	Japan		х
/KB/	AH	WO 02/35540 A1	05/2002	WIPO		х
	AI					
	AJ					
	AK					

OTHER REFERENCES (INCLUDING AUTHOR TITLE DATE REPTINENT PAGES FTC.)

0	IHEK	REFERENCES (INCLUDING AUTHO	R, IIILE, DATE, PERTIF	NENT PAGES	, EIC.)
					TRANSLATION YES NO
/KB/	AL	YATSUI et al., "Increasing Through Probe Over 1000 Times by the Use Applied Physics Letters, Vol. 73, No.	of a Triple-Tapered Stru		
/KB/	AM	FUJI et al., "A Near-Field Recording Metallic Probe in an Optical Disk", Vol. 39, Part I, No. 2B, February 20			
EXAMINER	/Ke	evin Bernatz/	DATE CONSIDERED	09/26/2008	

*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.